

| Ref # | Hits | Search Query  | DBs  | Default Operator | Plurals | Time Stamp       |
|-------|------|---|--|------------------|---------|------------------|
| L2    | 0    | "Alq3" with resistivity                                       | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR               | ON      | 2005/06/10 11:42 |
| L3    | 0    | "Alq3" with ohm   | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR               | ON      | 2005/06/10 11:42 |
| L4    | 0    | "Alq.sub.3" with ohm  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR               | ON      | 2005/06/10 11:42 |
| L5    | 0    | "quinolinolato"\$4 with resistivity                           | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB          | OR               | ON      | 2005/06/10 11:43 |
| L6    | 0    | "quinolinolato"\$4 with (specific adj resistance resistivity) | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB          | OR               | ON      | 2005/06/10 11:43 |
| L7    | 3    | "Alq.sub.3" with (specific adj resistance resistivity)        | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB          | OR               | ON      | 2005/06/10 11:51 |
| L8    | 1    | "6774561".pn.   | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB          | OR               | ON      | 2005/06/10 11:51 |
| L9    | 1    | 8 and (conductivity option\$4)                                | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB          | OR               | ON      | 2005/06/10 11:51 |
| L10   | 1    | "6831408".pn.   | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB          | OR               | ON      | 2005/06/10 12:27 |

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|-----|------|--|---|----|-----|------------------|
| L11 | 2    | 10 l8  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB             | OR | ON  | 2005/06/10 12:27 |
| L12 | 2    | 11 and laminate  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB             | OR | ON  | 2005/06/10 12:28 |
| L13 | 1    | "20040189186".did.   | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB             | OR | ON  | 2005/06/10 12:29 |
| L14 | 1    | 13 and laminate  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB             | OR | ON  | 2005/06/10 12:34 |
| L15 | 2    | 11 and alloy   | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB             | OR | ON  | 2005/06/10 12:34 |
| L16 | 2    | 11 and (blend\$5 mix mixed<br>mixture highly adj dispersed<br>dispersed knead\$4 admix\$6<br>scatter\$4) | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/10 14:15 |
| L17 | 174  | sony.as. and organic and laminate  | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/10 12:39 |
| L18 | 98   | sony.as. and organic and laminate<br>and alloy   | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/10 12:40 |
| L19 | 23   | sony.as. and organic and laminate<br>and alloy and display   | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/10 12:40 |
| L20 | 23   | 19 and alloy.bi.   | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/10 12:43 |
| L21 | 873  | (313/503).CCLS.  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/10 12:47 |
| L22 | 177  | 21 and alloy same oxide  | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/10 12:44 |
| L23 | 3    | 21 and alloy same oxide same<br>(chromium cr) same (niobium nb)  | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/10 12:47 |
| L24 | 3062 | (313/503,504).CCLS.  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2005/06/10 13:17 |

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| L25 | 8    | 24 and alloy same oxide same (chromium cr) same (niobium nb) same tungsten         | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/10 13:18 |
| L26 | 2    | "6885147".pn.  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/10 13:14 |
| L27 | 2    | 26 and (multilayer multi)  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/10 13:14 |
| L28 | 5548 | (313/503-512).CCLS.  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/06/10 13:31 |
| L29 | 9    | 28 and alloy same oxide same (chromium cr) same (niobium nb) same tungsten         | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/10 13:18 |
| L30 | 1    | 28 and alloy same oxide same (chromium cr) same (niobium nb) same tungsten not l25 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/10 13:19 |
| L31 | 0    | bierelein.in.  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/10 13:19 |
| L32 | 0    | bierlein.in. and anode adj modification adj. layer                                 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/10 13:19 |

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| L33 | 8   | anode adj modification adj layer   | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/10 13:20 |
| L34 | 1   | ("2002/0117962").URPN.   | USPAT   | OR | OFF | 2005/06/10 13:27 |
| L35 | 413 | 28 and ( (plural double triple multi dual) adj (coat\$5 layer\$5 jacket\$5 film skin plating plated sublayer sub adj layer lamina\$5 overcoat\$4 monolayer\$4) (multicoat\$5 multilayer\$5 multijacket\$5 multifilm multiskin multiplating multiplated multisublayer multisub adj layer multilamina\$5 multiovercoat\$4) bilayer trilayer) near5 (anode cathode electrode)                       | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/10 13:32 |
| L36 | 20  | 28 and ( (plural double triple multi dual) adj (coat\$5 layer\$5 jacket\$5 film skin plating plated sublayer sub adj layer lamina\$5 overcoat\$4 monolayer\$4) (multicoat\$5 multilayer\$5 multijacket\$5 multifilm multiskin multiplating multiplated multisublayer multisub adj layer multilamina\$5 multiovercoat\$4) bilayer trilayer) near5 (anode cathode electrode) same oxide same alloy | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/10 13:36 |
| L37 | 1   | "6831408".pn.  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/10 13:36 |
| L38 | 1   | 37 and oxide near5 (metallic metal)  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/10 13:37 |
| L39 | 1   | 37 and oxide   | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/10 13:40 |
| L40 | 1   | "6774561".pn.  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/10 13:40 |
| L41 | 1   | "6774561".PN.  | DERWENT   | OR | ON  | 2005/06/10 14:17 |
| L42 | 1   | 2002-500914.NRAN.  | DERWENT   | OR | OFF | 2005/06/10 14:15 |
| L43 | 0   | "WO-200134382-\$ did"  | DERWENT   | OR | ON  | 2005/06/10 14:17 |
| L44 | 0   | "WO-2002056641-\$ did"   | DERWENT   | OR | ON  | 2005/06/10 14:17 |
| L45 | 0   | "WO-200256641-\$ did"  | DERWENT   | OR | ON  | 2005/06/10 15:02 |
| L46 | 1   | 2002-500914.NRAN.  | DERWENT   | OR | OFF | 2005/06/10 14:18 |
| L47 | 1   | "6831408"  | USPAT   | OR | ON  | 2005/06/10 15:02 |
| L48 | 0   | 47 AND "CrO:sub.2"   | USPAT   | OR | ON  | 2005/06/10 15:02 |
| S1  | 1   | "20040189186".did.   | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 13:32 |

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| S2  | 2405 | (313/504).CCLS.  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2005/06/08 17:29 |
| S3  | 2405 | (313/504).CCLS.  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2005/06/08 19:14 |
| S4  | 288  | S3 and plasma near3 (treatment treated treating)   | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/08 17:29 |
| S5  | 111  | S3 and plasma near3 (treatment treated treating) with (electrode cathode anode)  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/08 18:05 |
| S6  | 7    | S3 and plasma near3 (treatment treated treating) with forming with (electrode cathode anode)   | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/08 17:33 |
| S8  | 1    | "20040189186".did  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/08 17:41 |
| S9  | 1    | S8 and laminate  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/08 17:41 |
| S10 | 75   | S3 and plasma near3 (treatment treated treating) with (electrode cathode anode) same (oxygen ozone "O. <sub>sub.2</sub> " "O. <sub>sub.3</sub> ")                                | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/08 18:06 |
| S11 | 7    | S3 and plasma near3 (treatment treated treating) with (electrode cathode anode) same (oxygen ozone "O. <sub>sub.2</sub> " "O. <sub>sub.3</sub> ") and resistivity and reflect\$6 | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/08 18:08 |

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| S12 | 4  | ( BOLED OLED OEL TOLED SOLED FOLED PLED (polymer organic) near2 (EL adj (apparatus device) light lamp luminaire electroluminesc\$9 electro adj luminesc\$9 EL ELD) OELD OED LESD) and plasma near3 (treatment treated treating).ab,ti, clm. with (electrode cathode anode) same (oxygen ozone "O. sub.2" "O.sub.3") and resistivity and reflect\$6   | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/08 18:08 |
| S13 | 8  | ( BOLED OLED OEL TOLED SOLED FOLED PLED (polymer organic) near2 (EL adj (apparatus device) light lamp luminaire electroluminesc\$9 electro adj luminesc\$9 EL ELD) OELD OED LESD).ab,ti,clm. and plasma near3 (treatment treated treating) with (electrode cathode anode) same (oxygen ozone "O.sub.2" "O.sub.3") and resistivity and reflect\$6   | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/08 18:22 |
| S14 | 34 | ( BOLED OLED OEL TOLED SOLED FOLED PLED (polymer organic) near2 (EL adj (apparatus device) light lamp luminaire electroluminesc\$9 electro adj luminesc\$9 EL ELD) OELD OED LESD).ab,ti,clm. and plasma near3 (treatment treated treating) with (electrode cathode anode) same (oxygen ozone "O.sub.2" "O.sub.3") and (resistivity resistance) and reflect\$6  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/08 19:10 |
| S15 | 47 | ( BOLED OLED OEL TOLED SOLED FOLED PLED (polymer organic) near2 (EL adj (apparatus device) light lamp luminaire electroluminesc\$9 electro adj luminesc\$9 EL ELD) OELD OED LESD).ab,ti,clm. and plasma near3 (treatment treated treating) with (electrode cathode anode) same (oxygen ozone "O.sub.2" "O.sub.3") and (resistivity resistance) and (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn in sn zn mo v ti ta nb) same plasma near3 (treatment treated treating) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/08 19:13 |

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| S16 | 27    | ( BOLED OLED OEL TOLED SOLED FOLED PLED (polymer organic) near2 (EL adj (apparatus device) light lamp luminaire electroluminesc\$9 electro adj luminesc\$9 EL ELD) OELD OED LESD).ab,ti,clm. and plasma near3 (treatment treated treating) with (electrode cathode anode) same (oxygen ozone "O. <sub>sub.2</sub> " "O. <sub>sub.3</sub> ") and (resistivity resistance) and (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) same plasma near3 (treatment treated treating)      | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/08 19:13 |
| S17 | 39    | (( BOLED OLED OEL TOLED SOLED FOLED PLED (polymer organic) near2 (EL adj (apparatus device) light lamp luminaire electroluminesc\$9 electro adj luminesc\$9 EL ELD) OELD OED LESD).ab,ti,clm. S3) and plasma near3 (treatment treated treating) with (electrode cathode anode) same (oxygen ozone "O. <sub>sub.2</sub> " "O. <sub>sub.3</sub> ") and (resistivity resistance) and (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) same plasma near3 (treatment treated treating) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/09 17:26 |
| S18 | 3482  | (313/504,506).CCLS.  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/06/08 20:27 |
| S19 | 38242 | (( BOLED OLED OEL TOLED SOLED FOLED PLED (polymer organic) near2 (EL adj (apparatus device) light lamp luminaire electroluminesc\$9 electro adj luminesc\$9 EL ELD) OELD OED LESD).ab,ti,clm. S3 S18)  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/09 13:20 |

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| S20 | 40   | S19 and plasma near3 (treatment treated treating) with (electrode cathode anode) same (oxygen ozone "O.sub.2" "O.sub.3") and (resistivity resistance) and (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) same plasma near3 (treatment treated treating)                                  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/08 19:46 |
| S21 | 88   | S19 and plasma near3 (treatment treated treating) with (electrode cathode anode) same (oxygen ozone "O.sub.2" "O.sub.3") and (resistivity resistance) and (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) with (electrode cathod\$2 anod\$2)  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/08 19:48 |
| S22 | 39   | S19 and plasma near3 (treatment treated treating) with (electrode cathode anode) same (oxygen ozone "O.sub.2" "O.sub.3") and (resistivity resistance) and (tungsten nickel chromium manganese zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) with (electrode cathod\$2 anod\$2) with (semitranspar\$6 semi adj transpar\$6 transpar\$6) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/09 14:27 |
| S23 | 3    | lyophilic near3 definition  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/08 20:15 |
| S24 | 11   | lyophilic near3 defined   | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/08 20:15 |
| S25 | 5519 | (313/503-512).CCLS.   | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/06/08 20:27 |

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| S26 | 0    | ("24notl17").PN.  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2005/06/08 20:27 |
| S27 | 1482 | S25 not S18   | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/08 20:27 |
| S28 | 0    | S27 and plasma near3 (treatment treated treating) with (electrode cathode anode) same (oxygen ozone "O.sub.2" "O.sub.3") and (resistivity resistance) and (tungsten nickel chromium manganese zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) with (electrode cathod\$2 anod\$2) with (semitranspar\$6 semi adj transpar\$6 transpar\$6) not S22 | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/08 20:28 |
| S29 | 0    | S27 and plasma near3 (treatment treated treating) with (electrode cathode anode) same (oxygen ozone "O.sub.2" "O.sub.3") and (resistivity resistance) and (tungsten nickel chromium manganese zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) with (electrode cathod\$2 anod\$2) with (semitranspar\$6 semi adj transpar\$6 transpar\$6) not S22 | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/08 20:28 |
| S30 | 0    | S19 and plasma near3 (treatment treated treating) with (electrode cathode anode) same (oxygen ozone "O.sub.2" "O.sub.3") and (resistivity resistance) and (tungsten nickel chromium manganese zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) with (electrode cathod\$2 anod\$2) with (semitranspar\$6 semi adj transpar\$6 transpar\$6) not S22 | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/08 20:28 |
| S31 | 7    | (US-20020030441-\$ or<br>US-20020033664-\$ or<br>US-20050023968-\$ or<br>US-20020011205-\$).did. or<br>(US-6853130-\$ or US-6869635-\$ or US-6576352-\$).did.   | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 11:30 |

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|-----|------|--|---|----|-----|------------------|
| S32 | 7    | S31 and plasma   | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 12:32 |
| S33 | 6    | S31 and plasma and (tungsten nickel chromium manganese zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) with (electrode cathod\$2 anod\$2) | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 11:41 |
| S34 | 1    | "6853130".pn.  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 11:41 |
| S35 | 1    | S34 and transparent adj electrode  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 11:45 |
| S36 | 1    | S34 and cathode same transparent   | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 11:43 |
| S37 | 1    | S34 and cathode same reflect\$6  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 11:44 |
| S38 | 1    | S34 and plasma same anode  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 12:40 |
| S39 | 1    | S34 and plasma same (cathode electrode anode)  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 12:29 |
| S40 | 1    | S34 and (resistance resistivity)   | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/09 12:30 |
| S41 | 1    | S34 and transmit\$7  | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/09 12:30 |
| S42 | 3    | S31 and plasma and visible adj region  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 12:37 |
| S43 | 5    | S31 and plasma and Ni  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 12:37 |
| S44 | 0    | S38 and (alloy combination)  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 12:41 |
| S45 | 1    | S38 and (blend\$5 mix mixed mixture highly adj dispersed dispersed knead\$4 admix\$6 scatter\$4)   | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/09 12:42 |
| S46 | 1    | S34 and (blend\$5 mix mixed mixture highly adj dispersed dispersed knead\$4 admix\$6 scatter\$4)   | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/10 12:38 |
| S47 | 2427 | (313/504).CCLS.  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2005/06/09 13:21 |

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| S48 | 3509  | (313/504,506).CCLS.   | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2005/06/09 13:21 |
| S49 | 38288 | (( BOLED OLED OEL TOLED SOLED FOLED PLED (polymer organic) near2 (EL adj (apparatus device) light lamp luminaire electroluminesc\$9 electro adj luminesc\$9 EL ELD) OELD OED LEESD).ab,ti,clm. S47 S48) | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/09 13:21 |
| S50 | 0     | ppv near5 resistivity   | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/09 13:21 |
| S51 | 1     | (ppv phenylenevinylene) near5 resistivity   | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/09 13:22 |
| S52 | 5     | (ppv phenylenevinylene) with resistivity  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/09 13:23 |
| S53 | 36    | nickel adj oxide near6 resistivity  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/09 13:23 |
| S54 | 1     | "20040189186".did.  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 13:32 |
| S55 | 1     | S54 and resistivity   | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 13:37 |
| S56 | 98872 | (platinum gold) adj oxide resistivity   | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 13:37 |
| S57 | 0     | (platinum gold) adj oxide near6 resistivity   | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 13:37 |
| S58 | 34    | (platinum gold iridium palladium) adj oxide with ((specific adj resistance) resistivity)  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 13:38 |

|     |   |  |                 |    |    |                  |
|-----|---|--|-----------------|----|----|------------------|
| S59 | 5 | S31 and (blend\$5 mix mixed mixture highly adj dispersed dispersed knead\$4 admix\$6 scatter\$4)   | US-PGPUB; USPAT | OR | ON | 2005/06/09 14:28 |
| S60 | 5 | S31 and (blend\$5 mix mixed mixture highly adj dispersed dispersed knead\$4 admix\$6 scatter\$4) and (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb)                                       | US-PGPUB; USPAT | OR | ON | 2005/06/09 14:29 |
| S61 | 4 | S31 and (blend\$5 mix mixed mixture highly adj dispersed dispersed knead\$4 admix\$6 scatter\$4) and (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) same (electrode cathode anode)        | US-PGPUB; USPAT | OR | ON | 2005/06/09 14:30 |
| S62 | 1 | S31 and (blend\$5 mix mixed mixture highly adj dispersed dispersed knead\$4 admix\$6 scatter\$4) same (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) same (electrode cathode anode)       | US-PGPUB; USPAT | OR | ON | 2005/06/09 14:30 |
| S63 | 1 | S31 and (alloy blend\$5 mix mixed mixture highly adj dispersed dispersed knead\$4 admix\$6 scatter\$4) same (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) same (electrode cathode anode) | US-PGPUB; USPAT | OR | ON | 2005/06/09 14:31 |
| S64 | 1 | S31 and (alloy blend\$5 mix mixed mixture highly adj dispersed dispersed knead\$4 admix\$6 scatter\$4) same (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) same (electrode cathode anode) | US-PGPUB; USPAT | OR | ON | 2005/06/09 14:32 |

|     |     |  |                          |    |     |                  |
|-----|-----|--|--------------------------|----|-----|------------------|
| S65 | 1   | S31 and (alloy blend\$5 mix mixed mixture highly adj dispersed dispersed knead\$4 admix\$6 scatter\$4) same (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) same (electrode cathode anode) and plasma  | US-PGPUB; USPAT          | OR | ON  | 2005/06/09 14:38 |
| S66 | 440 | S49 and (alloy blend\$5 mix mixed mixture highly adj dispersed dispersed knead\$4 admix\$6 scatter\$4) same (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) same (electrode cathode anode) and plasma near6 (oxygen ozone "O. <sub>2</sub> " "O. <sub>3</sub> ")   | US-PGPUB; USPAT          | OR | ON  | 2005/06/09 14:39 |
| S67 | 132 | S49 and (alloy blend\$5 mix mixed mixture highly adj dispersed dispersed knead\$4 admix\$6 scatter\$4) same (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) same (electrode cathode anode) and plasma near6 (oxygen ozone "O. <sub>2</sub> " "O. <sub>3</sub> ") with (anode electrode cathode)  | US-PGPUB; USPAT          | OR | ON  | 2005/06/09 14:41 |
| S68 | 84  | S49 and (alloy blend\$5 mix mixed mixture highly adj dispersed dispersed knead\$4 admix\$6 scatter\$4) same (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) same (electrode cathode anode) and plasma near6 (oxygen ozone "O. <sub>2</sub> " "O. <sub>3</sub> ") near6 (treatment treat treating treated) with (anode electrode cathode) | US-PGPUB; USPAT          | OR | ON  | 2005/06/09 14:47 |
| S69 | 2   | "6713781".pn.  | US-PGPUB; USPAT; DERWENT | OR | ON  | 2005/06/09 15:15 |
| S70 | 1   | 2004-326636.NRAN.  | DERWENT                  | OR | OFF | 2005/06/09 14:47 |
| S71 | 2   | "6885147".pn.  | US-PGPUB; USPAT; DERWENT | OR | ON  | 2005/06/09 15:15 |

|     |       |   |   |    |     |                  |
|-----|-------|---|---|----|-----|------------------|
| S72 | 1     | S71 and plasma  | US-PGPUB;<br>USPAT;<br>DERWENT                                    | OR | ON  | 2005/06/09 15:21 |
| S73 | 2     | "20010051487".did. and plasma   | US-PGPUB;<br>USPAT;<br>DERWENT                                    | OR | ON  | 2005/06/09 15:22 |
| S74 | 1     | "6869635".pn.   | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 15:58 |
| S75 | 13329 | cathode with (material formed made) and plasma  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 15:59 |
| S76 | 13329 | "1" and cathode with (material formed made) and plasma  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 15:59 |
| S77 | 1     | S74 and cathode with (material formed made) and plasma  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 16:07 |
| S78 | 149   | aluminum adj oxide near6 resistivity  | US-PGPUB;<br>USPAT  | OR | OFF | 2005/06/09 16:13 |
| S79 | 39    | (Mori near2 Toshitaka Oyagi near2 Yasuyuki Kido near2 Junji).in.                              | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/09 16:13 |
| S80 | 1     | S79 and plasma.clm.   | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/09 16:14 |
| S81 | 6     | S79 and injection.clm.  | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/09 17:23 |
| S82 | 1     | "6835130".pn.   | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/09 17:23 |
| S83 | 1     | "6853130".pn.   | US-PGPUB;<br>USPAT  | OR | ON  | 2005/06/09 17:23 |
| S84 | 2     | "6853130".pn.   | US-PGPUB;<br>USPAT;<br>DERWENT                                    | OR | ON  | 2005/06/09 17:25 |
| S85 | 1     | 2002-414660.NRAN.   | DERWENT   | OR | OFF | 2005/06/09 17:23 |
| S86 | 954   | (313/503).CCLS.   | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | OFF | 2005/06/09 17:25 |
| S87 | 23    | S86 and (oxygen ozone "O.sub.2"<br>"O.sub.3") near6 plasma near3 (treatment treated treating) | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/09 17:51 |

|     |      |   |  |    |     |                  |
|-----|------|---|--|----|-----|------------------|
| S88 | 27   | (US-20010051487-\$ or US-20020011205-\$ or US-20020030441-\$ or US-20020033664-\$ or US-20020039730-\$ or US-20020160553-\$ or US-20030039858-\$ or US-20030062826-\$ or US-20030137242-\$ or US-20030146695-\$ or US-20030197466-\$ or US-20040082250-\$ or US-20040232830-\$ or US-20050023968-\$ or US-20050057136-\$ or US-20050057151-\$ or US-20020021088-\$).did. or (US-6576352-\$ or US-6626722-\$ or US-6764777-\$ or US-6853130-\$ or US-6869635-\$ or US-6303494-\$ or US-6060826-\$ or US-6768258-\$ or US-6853134-\$ or US-6885147-\$).did. | US-PGPUB; USPAT                                    | OR | OFF | 2005/06/09 17:26 |
| S89 | 19   | S87 not S88   | US-PGPUB; USPAT                                    | OR | OFF | 2005/06/09 17:34 |
| S90 | 5    | S87 and oxidiz\$6 not S88   | US-PGPUB; USPAT                                    | OR | OFF | 2005/06/09 17:49 |
| S91 | 4729 | ((257/40) or (362/800) or (315/169.3)).CCLS   | US-PGPUB; USPAT                                    | OR | OFF | 2005/06/09 17:51 |
| S92 | 69   | S91 and (oxygen ozone "O. <sub>sub.2</sub> " "O. <sub>sub.3</sub> ") near6 plasma near3 (treatment treated treating)  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON  | 2005/06/09 17:51 |
| S93 | 2427 | (313/504).CCLS.   | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/06/09 17:51 |
| S94 | 3509 | (313/504,506).CCLS.   | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | OFF | 2005/06/09 17:51 |

|      |       |   |  |    |    |                  |
|------|-------|---|--|----|----|------------------|
| S95  | 38288 | (( BOLED OLED OEL TOLED SOLED FOLED PLED (polymer organic) near2 (EL adj (apparatus device) light lamp luminaire electroluminesc\$9 electro adj luminesc\$9 EL ELD) OELD OED LESD).ab,ti,clm. S93 S94)  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/09 17:51 |
| S96  | 84    | S95 and (alloy:blend\$5 mix mixed mixture highly:adj dispersed dispersed knead\$4 admix\$6 scatter\$4) same (tungsten nickel chromium manganese indium tin zinc molybdenum vanadium titanium tantalum niobium cr ni mn sn zn mo v ti ta nb) same (electrode cathode anode) and plasma near6 (oxygen ozone "O. sub.2" "O.sub.3") near6 (treatment treat treating treated) with (anode electrode cathode) | US-PGPUB; USPAT                                    | OR | ON | 2005/06/09 17:51 |
| S97  | 60    | S91 and (oxygen ozone "O.sub.2" "O.sub.3") near6 plasma near3 (treatment treated treating) not S96  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/09 17:53 |
| S98  | 8     | S91 and (electrode cathode anode) with (oxygen ozone "O. sub.2" "O.sub.3") near6 plasma near3 (treatment treated treating) not S96  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/09 18:27 |
| S99  | 264   | hirano near2 takayuki.in.   | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/09 18:28 |
| S100 | 1     | S99 and negative adj electrode near3 K  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/09 18:28 |
| S101 | 7     | S99 and negative adj electrode  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/09 18:28 |

|          |        |   |   |    |    |                  |
|----------|--------|---|---|----|----|------------------|
| S10<br>2 | 283114 | sony.as.                                    | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2005/06/09 18:29 |
| S10<br>3 | 6      | S102 and negative adj electrode<br>near 5 K | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2005/06/09 18:30 |
| S10<br>4 | 6      | S99 and 3c                                  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2005/06/09 18:30 |
| S10<br>5 | 264    | hirano near2 takayuki.in.                   | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2005/06/09 18:49 |
| S10<br>6 | 0      | S105 and chromium adj oxide                 | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2005/06/09 18:59 |
| S10<br>7 | 2      | "2002216976"                                | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2005/06/09 19:48 |
| S10<br>8 | 4      | "2001043980"                                | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2005/06/09 19:18 |
| S10<br>9 | 2      | "6831408".pn.                               | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON | 2005/06/09 19:48 |

|          |   |  |   |    |     |                  |
|----------|---|--|---|----|-----|------------------|
| S11<br>0 | 1 | S109 and oxide                             | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/09 20:06 |
| S11<br>1 | 2 | "6774561".pn.                              | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>DERWENT;<br>IBM_TDB | OR | ON  | 2005/06/09 20:09 |
| S11<br>2 | 1 | 2002-500914.NRAN.                          | DERWENT   | OR | OFF | 2005/06/09 20:06 |
| S11<br>3 | 1 | "6774561".pn.                              | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB             | OR | ON  | 2005/06/09 20:14 |
| S11<br>4 | 0 | S113 and plasma                            | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB             | OR | ON  | 2005/06/09 20:16 |
| S11<br>5 | 1 | S113 and reflectivity                      | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB             | OR | ON  | 2005/06/09 20:18 |
| S11<br>6 | 1 | "6831408".pn.                              | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB             | OR | ON  | 2005/06/09 20:22 |
| S11<br>7 | 0 | ALq3 near5 resistivity                     | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB             | OR | ON  | 2005/06/09 20:22 |
| S11<br>8 | 0 | ALq3 with resistivity                      | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB             | OR | ON  | 2005/06/09 20:24 |
| S11<br>9 | 0 | quinolinol near2 aluminum with resistivity | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB             | OR | ON  | 2005/06/09 20:23 |

|       |        |  |   |    |    |                  |
|-------|--------|--|---|----|----|------------------|
| S12 0 | 121899 | resistivity  | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB | OR | ON | 2005/06/09 20:23 |
| S12 1 | 5      | quinolinol near2 aluminum with conductivity              | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB | OR | ON | 2005/06/09 20:50 |
| S12 2 | 0      | "ALq3" with resistivity                                  | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB | OR | ON | 2005/06/09 20:25 |
| S12 3 | 20     | "ALq3" with (conductivity electroconductivity)           | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB | OR | ON | 2005/06/09 20:24 |
| S12 4 | 0      | "ALq3" with (specific adj resistance)                    | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB | OR | ON | 2005/06/09 20:25 |
| S12 5 | 0      | quinolinol near2 aluminum with (specific adj resistance) | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB | OR | ON | 2005/06/09 20:37 |
| S12 6 | 0      | quinolinol near3 aluminum with (resistivity)             | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB | OR | ON | 2005/06/09 20:37 |
| S12 7 | 0      | quinolinol near4 aluminum with (resistivity)             | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB | OR | ON | 2005/06/09 20:37 |
| S12 8 | 0      | quinolinol near4 (al aluminum) with (resistivity)        | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB | OR | ON | 2005/06/09 20:39 |
| S12 9 | 1      | Alq with (resistivity)                                   | US-PGPUB; USPAT; USOCR; EPO; JPO; IBM_TDB | OR | ON | 2005/06/09 20:39 |

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|----------|------|---|---|----|----|------------------|
| S13<br>0 | 0    | quinolinol with (resistivity specific adj resistance) | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB | OR | ON | 2005/06/09 20:50 |
| S13<br>1 | 1009 | Alq3  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB | OR | ON | 2005/06/09 20:51 |
| S13<br>2 | 0    | aluminum near4 quinolinolato with resistivity         | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB | OR | ON | 2005/06/09 20:51 |
| S13<br>3 | 0    | quinolinolato with resistivity                        | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB | OR | ON | 2005/06/10 11:43 |
| S13<br>4 | 2    | quinolinolato with conductivity                       | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB | OR | ON | 2005/06/09 20:52 |
| S13<br>5 | 3    | "AlQ.sub.3" with resistivity                          | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB | OR | ON | 2005/06/09 20:53 |
| S13<br>6 | 18   | "AlQ.sub.3" same resistivity                          | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB | OR | ON | 2005/06/09 21:04 |
| S13<br>7 | 1    | "6831408".pn.   | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB | OR | ON | 2005/06/10 12:26 |
| S13<br>8 | 1    | S137 and alloy  | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB | OR | ON | 2005/06/09 21:05 |
| S13<br>9 | 1    | S137 and dual   | US-PGPUB;<br>USPAT;<br>USOCR;<br>EPO; JPO;<br>IBM_TDB | OR | ON | 2005/06/09 21:05 |

|       |     |  |  |    |    |                  |
|-------|-----|--|--|----|----|------------------|
| S14 0 | 104 | chromium adj oxide with resistivity                                  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/10 11:23 |
| S14 1 | 8   | "Cr <sub>2</sub> O <sub>3</sub> " with resistivity                   | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/10 11:34 |
| S14 2 | 10  | "Alq <sub>3</sub> " with (conductivity resistivity)                  | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/10 11:31 |
| S14 3 | 25  | hydroxyquinoline with (conductivity resistivity)                     | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/10 11:31 |
| S14 4 | 5   | hydroxyquinoline near4 (aluminum al) with (conductivity resistivity) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/10 11:32 |
| S14 5 | 13  | "CrO <sub>2</sub> " with resistivity                                 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB | OR | ON | 2005/06/10 11:41 |